

Title (en)
Semiconductor devices having air gaps

Title (de)
Halbleiterbauelemente mit Luftisolation

Title (fr)
Dispositifs semi-conducteurs comprenant des espaces d'air

Publication
EP 1926140 A2 20080528 (EN)

Application
EP 08101681 A 20060609

Priority
• EP 06115226 A 20060609
• US 15113405 A 20050613

Abstract (en)
Devices are obtained by using methods of forming air gaps between interconnects of integrated circuits and structures thereof. A first insulating material is deposited over a workpiece, and a second insulating material having a sacrificial portion is deposited over the first insulating material. Conductive lines are formed in the first and second insulating layers. The second insulating material is treated to remove the sacrificial portion, and at least a portion of the first insulating material is removed, forming air gaps between the conductive lines. The second insulating material is impermeable as deposited and permeable after treating it to remove the sacrificial portion. A first region of the workpiece may be masked during the treatment, so that the second insulating material becomes permeable in a second region of the workpiece yet remains impermeable in the first region, thus allowing the formation of the air gaps in the second region, but not the first region.

IPC 8 full level
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CPC (source: EP US)
H01L 21/7682 (2013.01 - EP US); **H01L 23/5222** (2013.01 - EP US); **H01L 2924/0002** (2013.01 - EP US)

Citation (applicant)
• US 2005087875 A1 20050428 - FURUKAWA TOSHIHARU [US], et al
• US 6413852 B1 20020702 - GRILL ALFRED [US], et al
• US 6693355 B1 20040217 - GROVE NICOLE R [US]

Designated contracting state (EPC)
DE FR IT

DOCDB simple family (publication)
EP 1739737 A1 20070103; EP 1926140 A2 20080528; EP 1926140 A3 20080709; EP 2015355 A2 20090114; EP 2015355 A3 20100106; JP 2006352124 A 20061228; JP 2011009769 A 20110113; JP 5308414 B2 20131009; US 2006281295 A1 20061214; US 2010032841 A1 20100211; US 2010144112 A1 20100610; US 2011278730 A1 20111117; US 7629225 B2 20091208; US 8013364 B2 20110906; US 8148235 B2 20120403; US 9401322 B2 20160726

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EP 06115226 A 20060609; EP 08101681 A 20060609; EP 08167853 A 20060609; JP 2006163346 A 20060613; JP 2010184816 A 20100820; US 15113405 A 20050613; US 201113190310 A 20110725; US 57980709 A 20091015; US 61856709 A 20091113